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PATENT

Attorney Docket No. TSMC2001-0999 (N1085-90151)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Shi-Chi Lin

Confirmation No.: 8321

Serial No.: 10/650,601

Group Art Unit: 2815

Filed: August 28, 2003

Examiner: José R. Diaz

For: METHOD OF MANUFACTURING  
DIELECTRIC ISOLATED SILICON  
STRUCTURE

Mail Stop Non-Fee Amendment  
Commissioner for Patents  
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January 11, 2005  
Date Steven E. Koffs  
Steven E. Koffs, Registration No. 37,163

RESPONSE TO RESTRICTION REQUIREMENT

Dear Sir:

This is in response to the Restriction Requirement dated December 15, 2004. The Examiner requires an election between Group I: Claims 1-18, drawn to a method of forming an intermediate dielectric isolated silicon structure, classified in class 438, subclass 221+. or Group II: Claims 19-20, drawn to a silicon-dioxide isolated epitaxial silicon structure classified in class 257, subclass 510+.

Applicant hereby elects Group I, claims 1-18. This election is made without traverse.

DATE:

1/11/05

Respectfully submitted,

Steven E. Koffs  
Steven E. Koffs

Registration No. 37,163

Attorney for Applicant(s)

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